PATENT NUMBER and ISSUE DATE

U.S. UTILITY Patent Application

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**CONTINUING DATA VERIFIED: THIS APPLICATIONS BENEFIT OF 60/260.883 01/12/2001 AND A CIP OF PCT/JP01/05800 07/04/2001 **FOREIGN APPLICATIONS VERIFIED: APAN 2000-204163 07/05/2000 GFUB DO NOT PUBLISH	APPL NUM 10042154	FILING DATE 01/11/2002	CLASS 516	SUBCLASS 077	GAU 1712	EXAMINER METZMAIER	
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THIS APPLN CLAIMS BENEFIT OF 60/260,883 01/12/2001 AND A CIP OF PCT/JP01/05800 07/04/2001 FOREIGN APPLICATIONS VERIFIED: APAN 2000-204163 07/05/2000 APPLICATIONS VERIFIED: APAN 2000-204163 07/05/2000 RESCIND RESCIND ATTORNEY DOCKET NO 1985 no ATTORNEY DOCKET NO 1985 no Q62628 ILE: Polishing composition and magnetic recording disk substrate polished with the polishing 1905/110-110-110-110-110-110-110-110-110-110						· · · · · · · · · · · · · · · · · · ·	V.5.
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NOTICE OF ALLOWANCE MAILED	• · · · · · · · · · · · · · · · · · · ·	CLAIMS ALLOWED			
	Assistant Examiner	Total Claims	* :	Print Claim for O.G	
Amount Due Date Paid		DRAWING			
		Sheets Drwg.	Figs.Dn		
	Primary Examiner			-	
TERMINAL	PREPARED FOR ISSUE	Application	Examine	or -	
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